

Prospects in molecular electronics devices based on supramolecular chemistry

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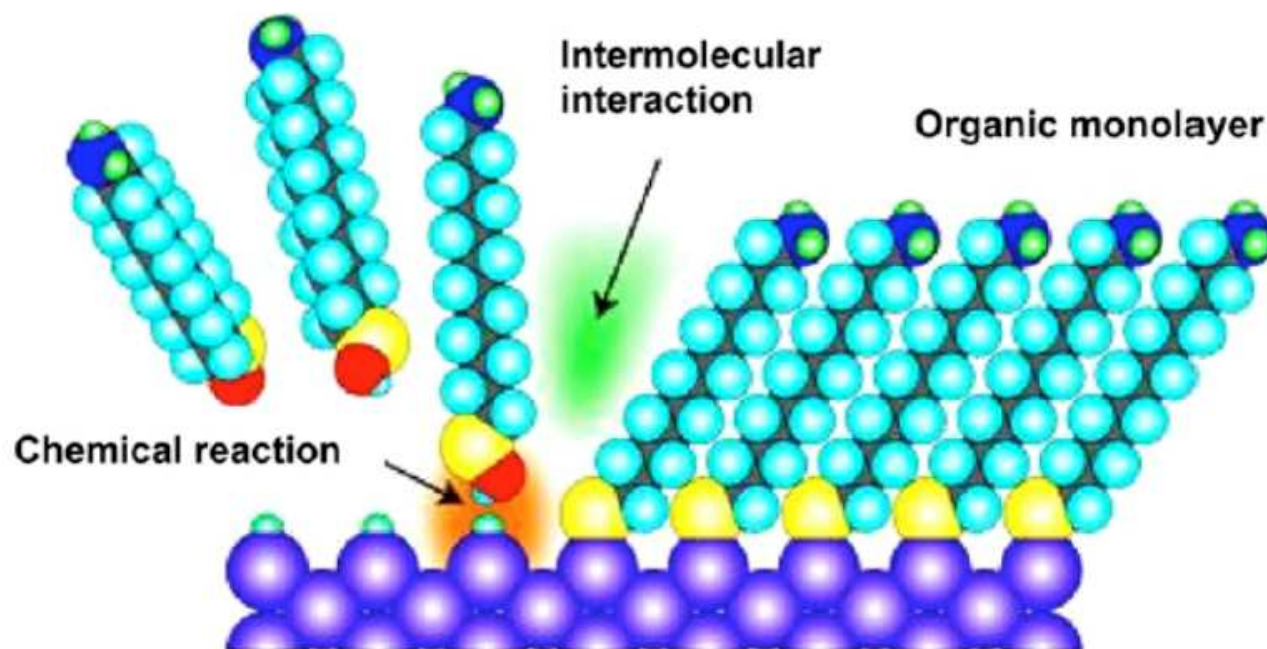
- What is "supramolecular chemistry" relevant to this talk?
- Nanodielectrics
- Monolayer transistors
- Monolayer memories and switches

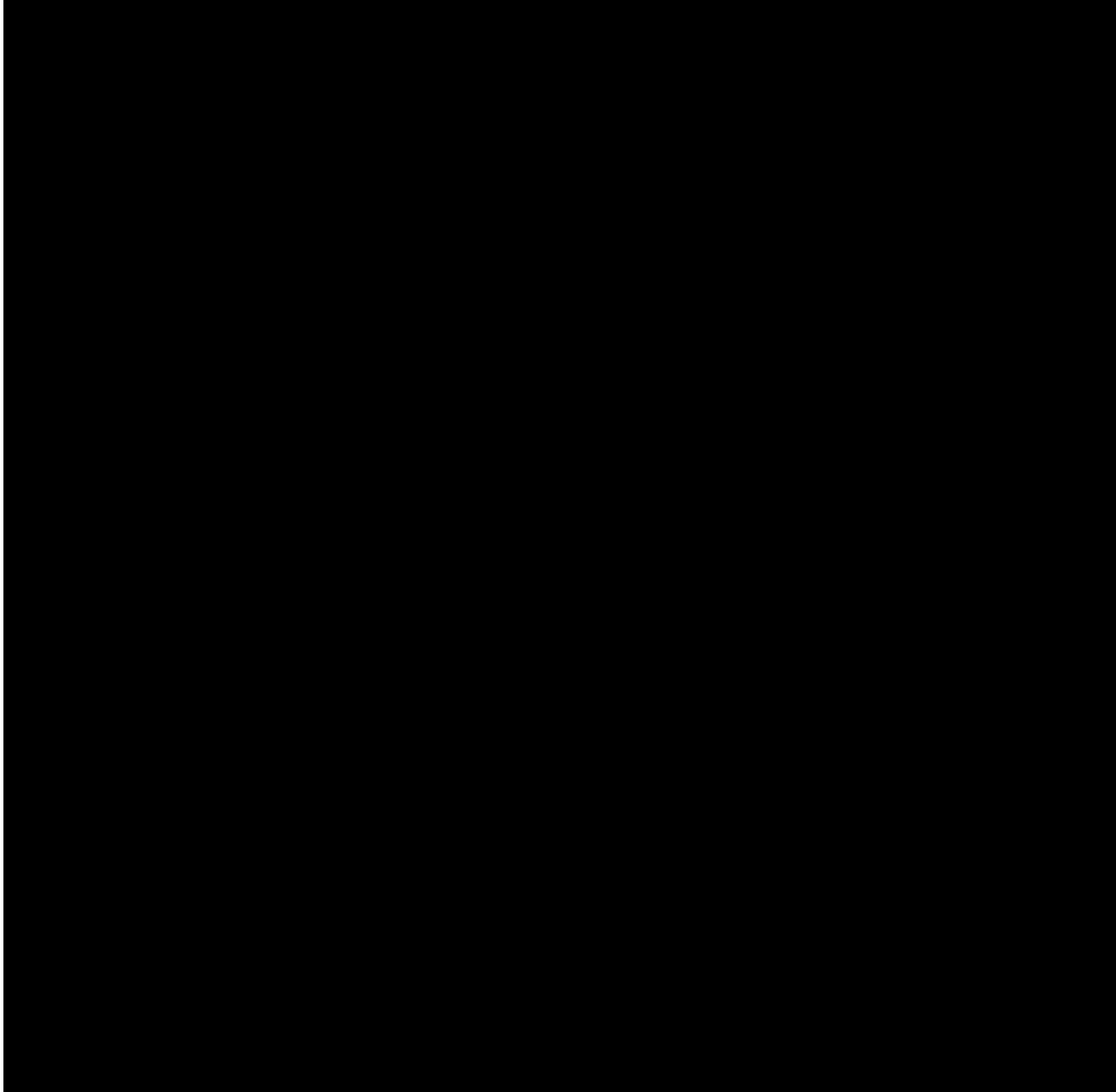
of supramolecular chemistry

"... consists in the design of systems undergoing self-organization, that is, systems capable of spontaneously generating a well-defined supramolecular architecture by self-assembling from their components under a given set of conditions."

J.M. Lehn, *Angew. Chem. Int. Ed.* (19

SAM : self-assembled mono- or multi-layers

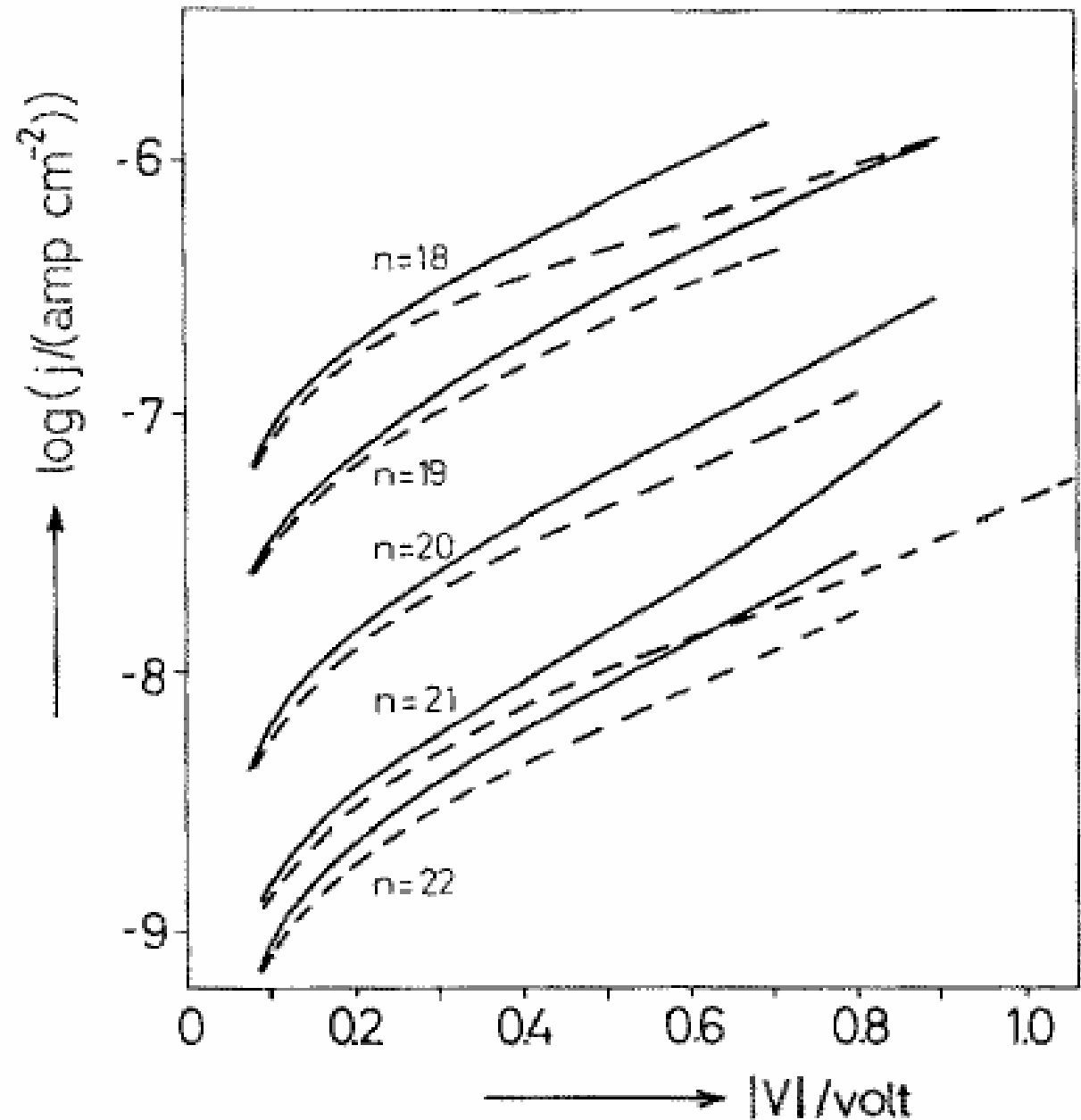
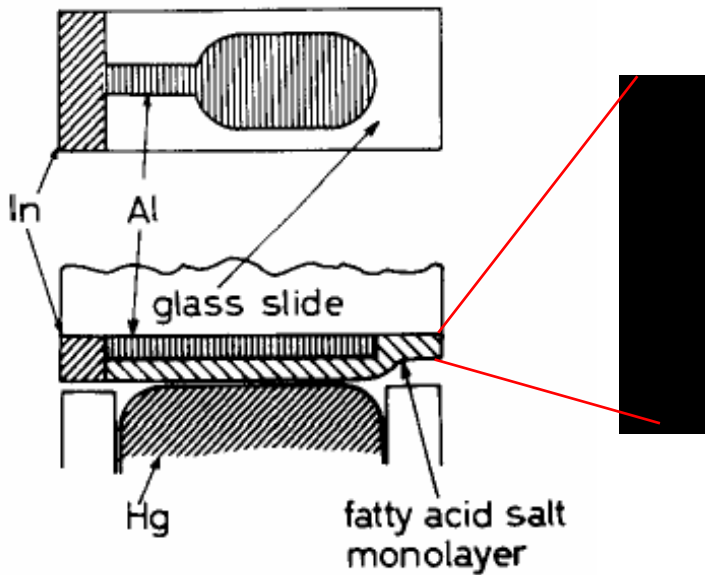


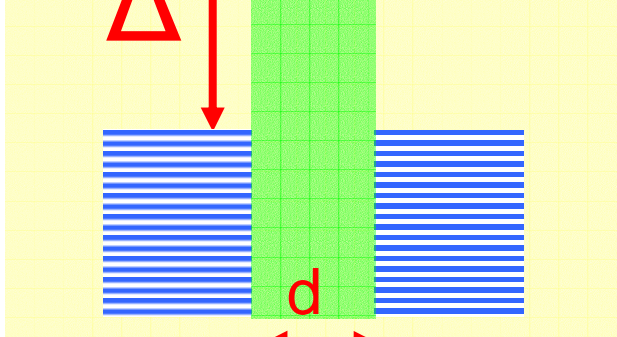


Not a recent story

Mann & Kuhn, J. Appl. Phys. (1971)

1st evidence of tunneling through a fatty acid LB monolayer sandwiched between metal electrodes

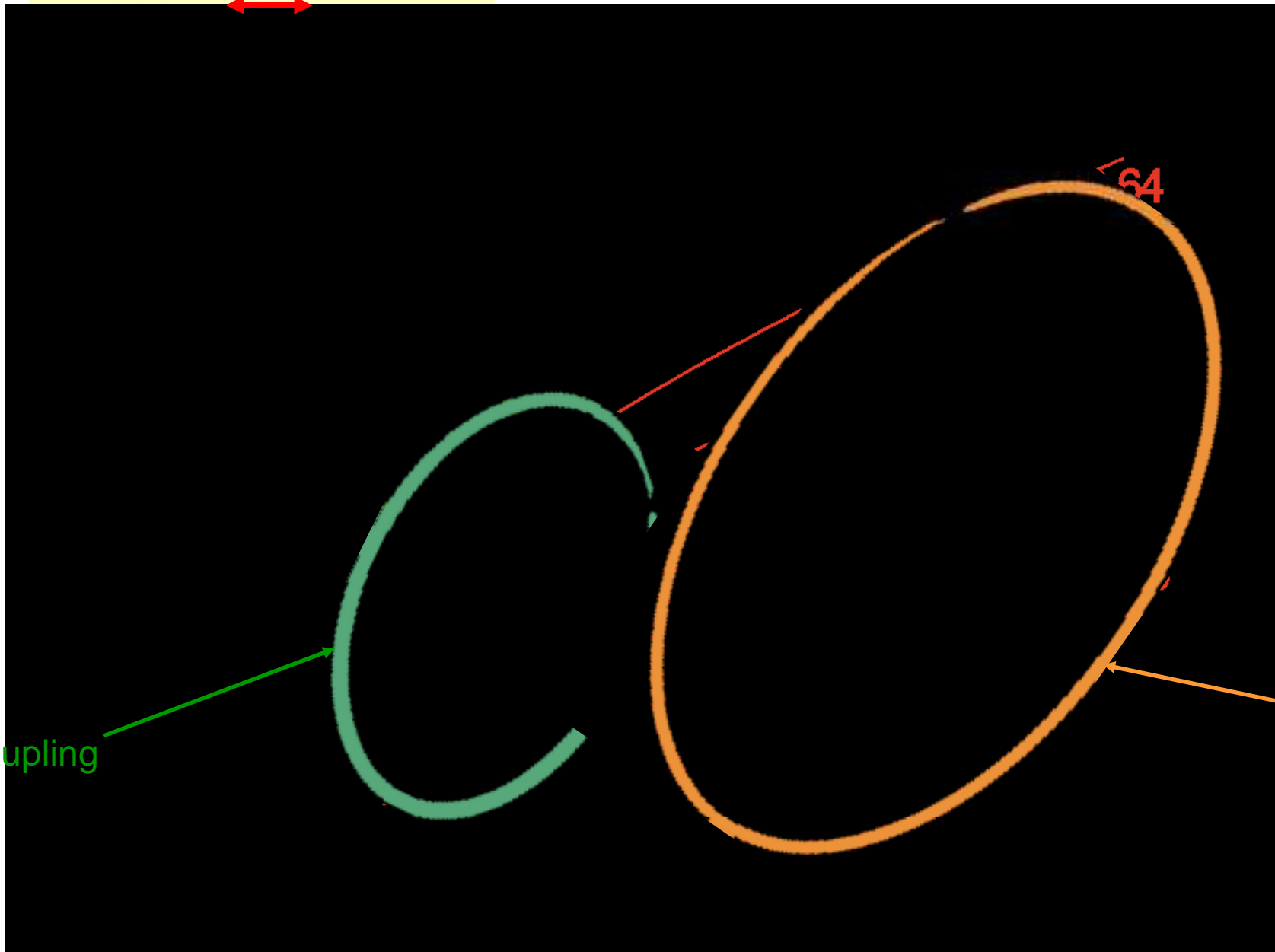




$$J = J_0 e^{-\beta d}$$

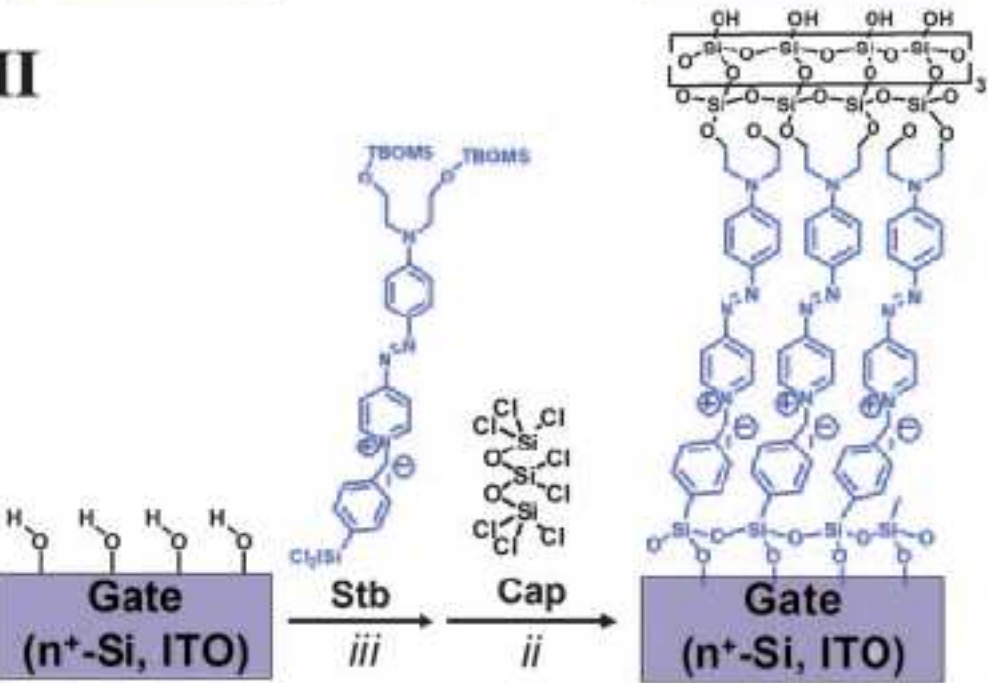
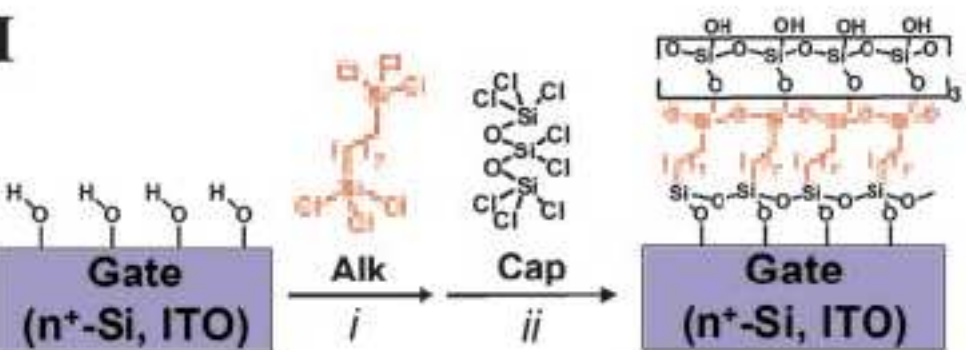
$$R = R_0 e^{\beta d}$$

$$\beta = \alpha \sqrt{\frac{m^*}{m_0}} \sqrt{\Delta}$$

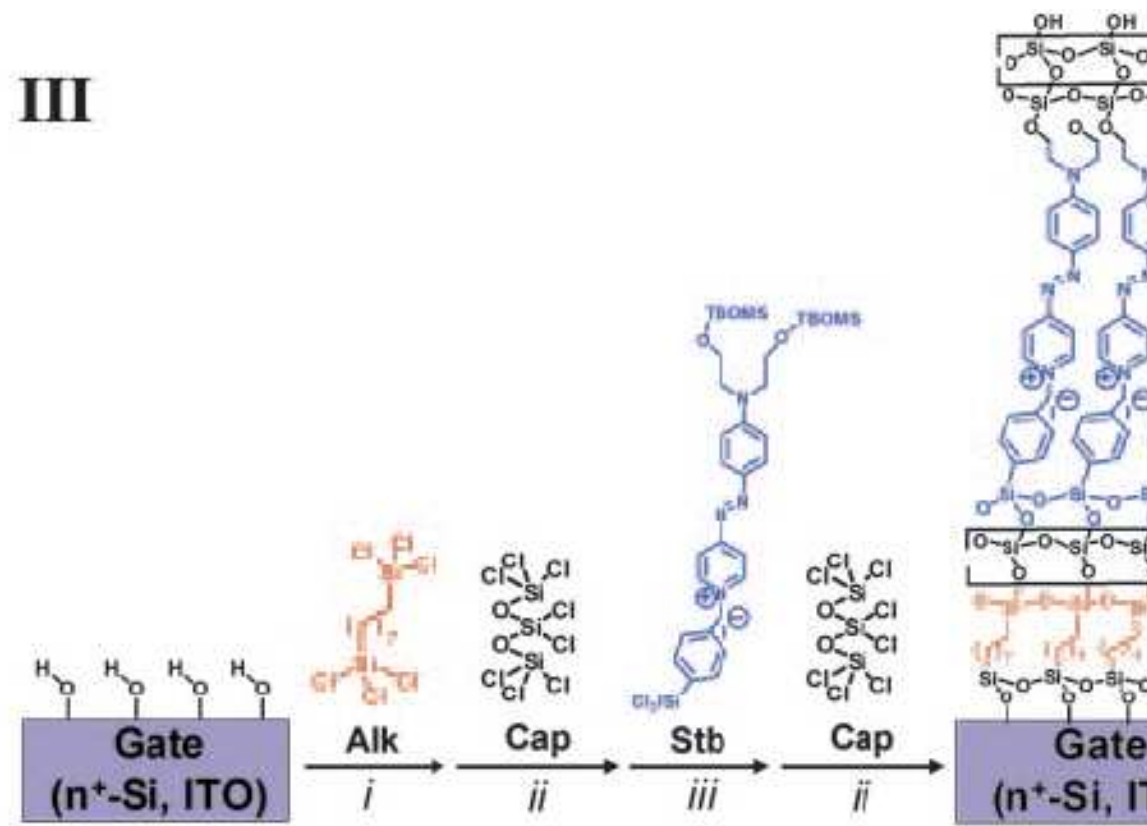


"strong" coupling

"weak" coupling

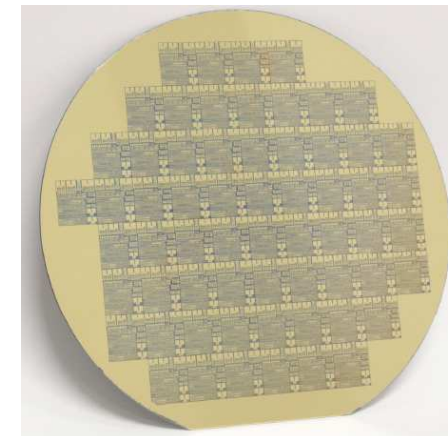
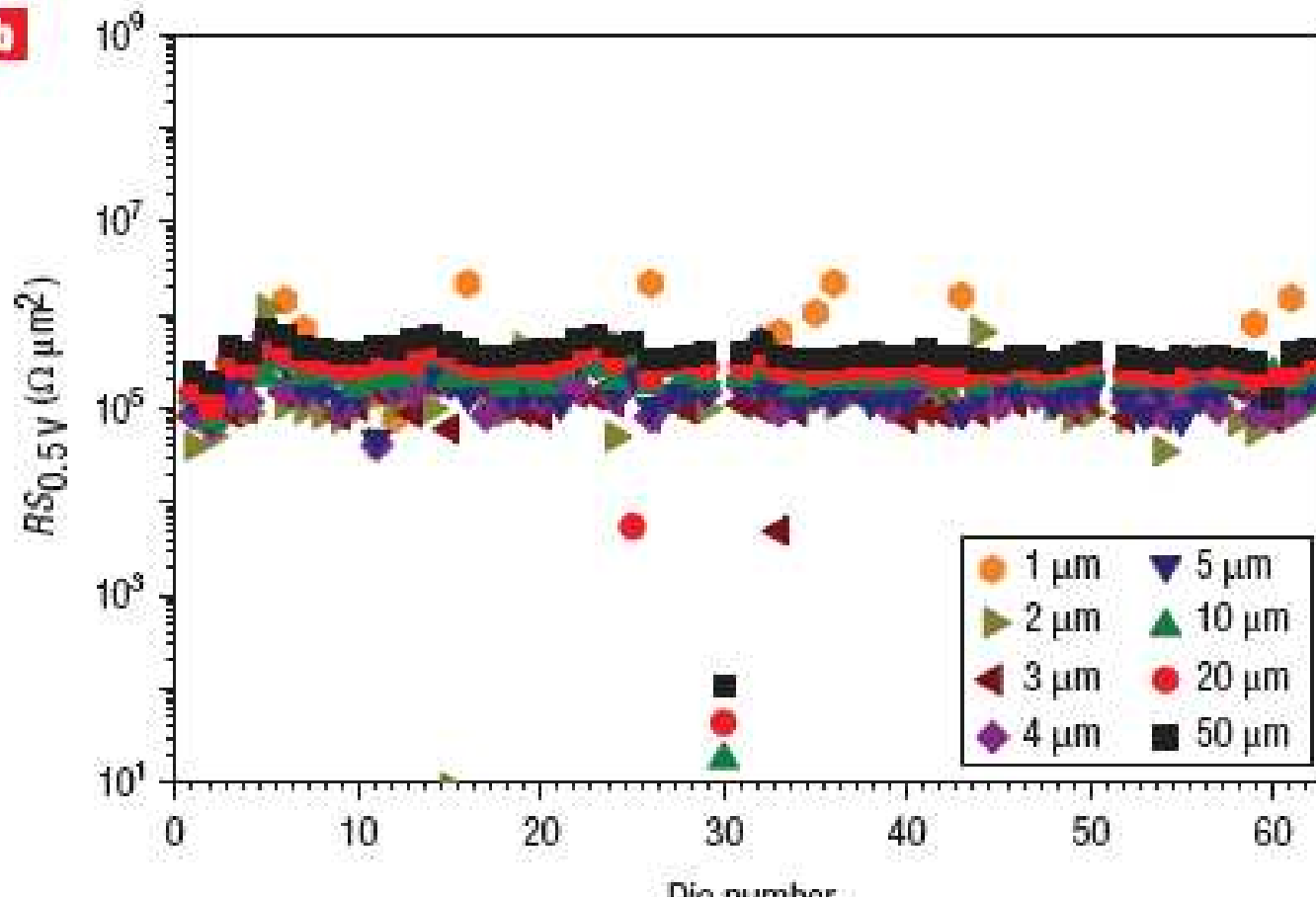
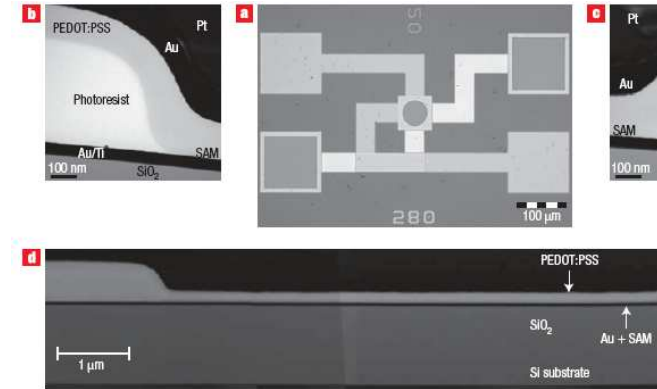
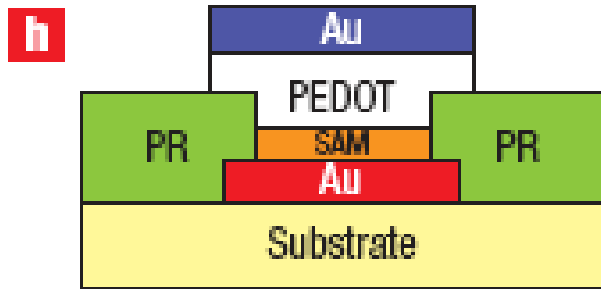


III

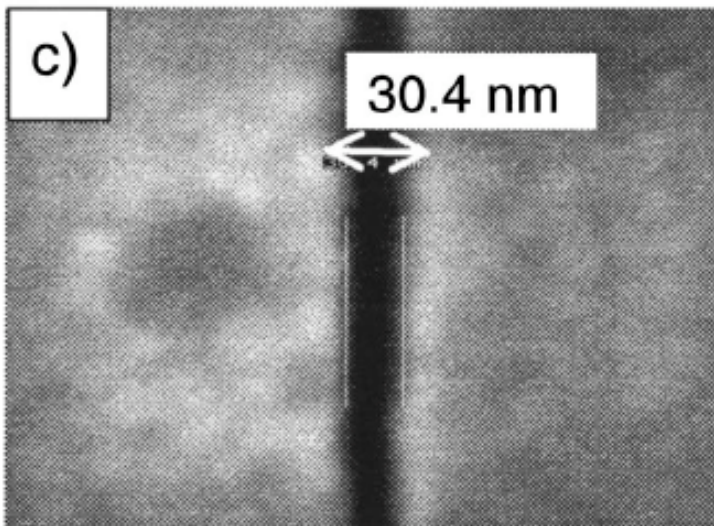
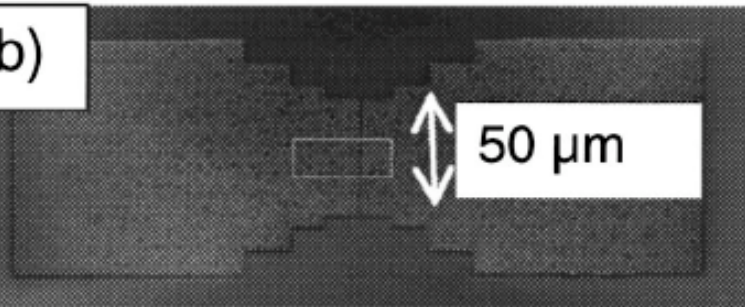
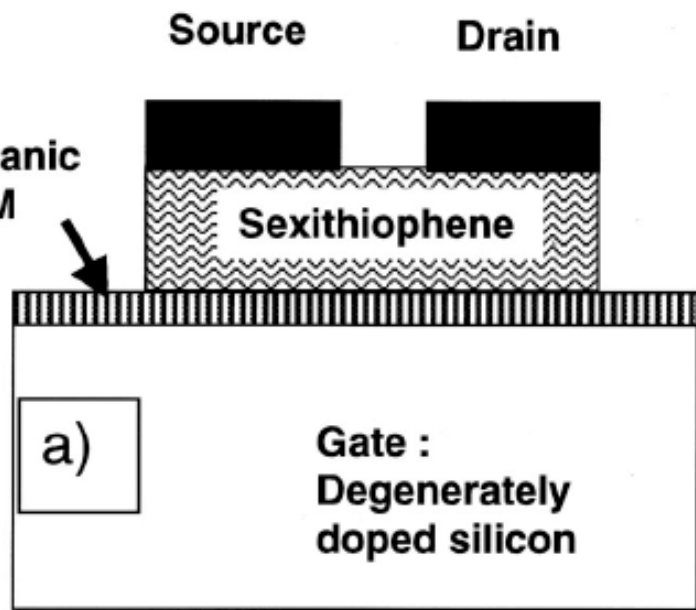


high-k SANDs : $\epsilon_R \approx 5-10$
 $I_{leak} \approx 10^{-7} \text{ A/cm}^2 \text{ @ } 1\text{V}$
 $E_{BD} \approx 7 - 10 \text{ MV/cm}$

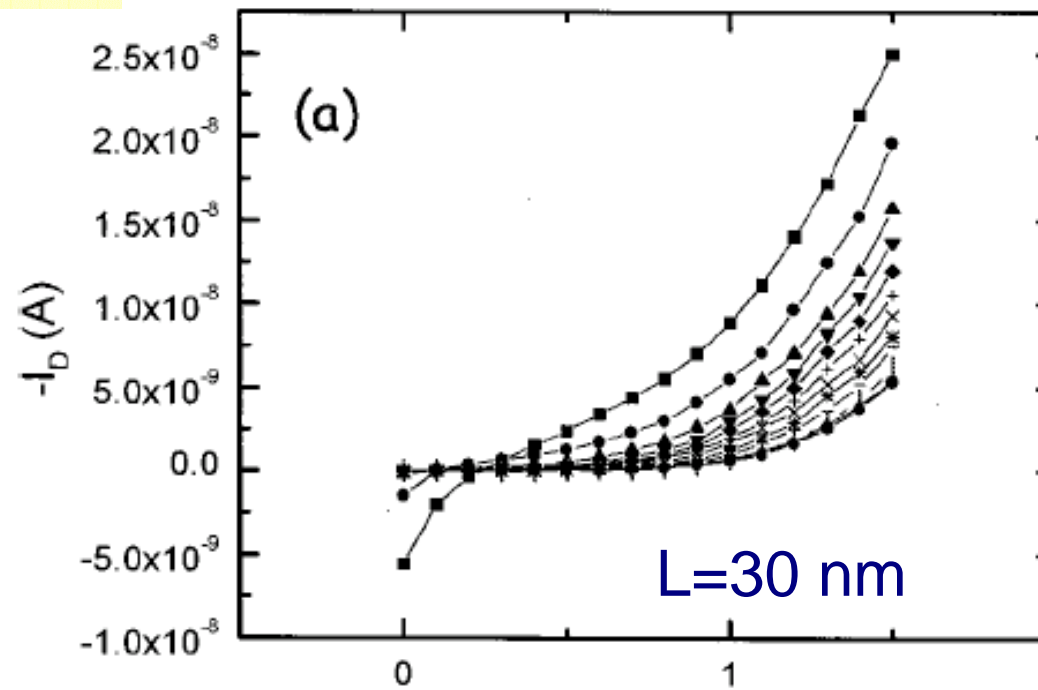
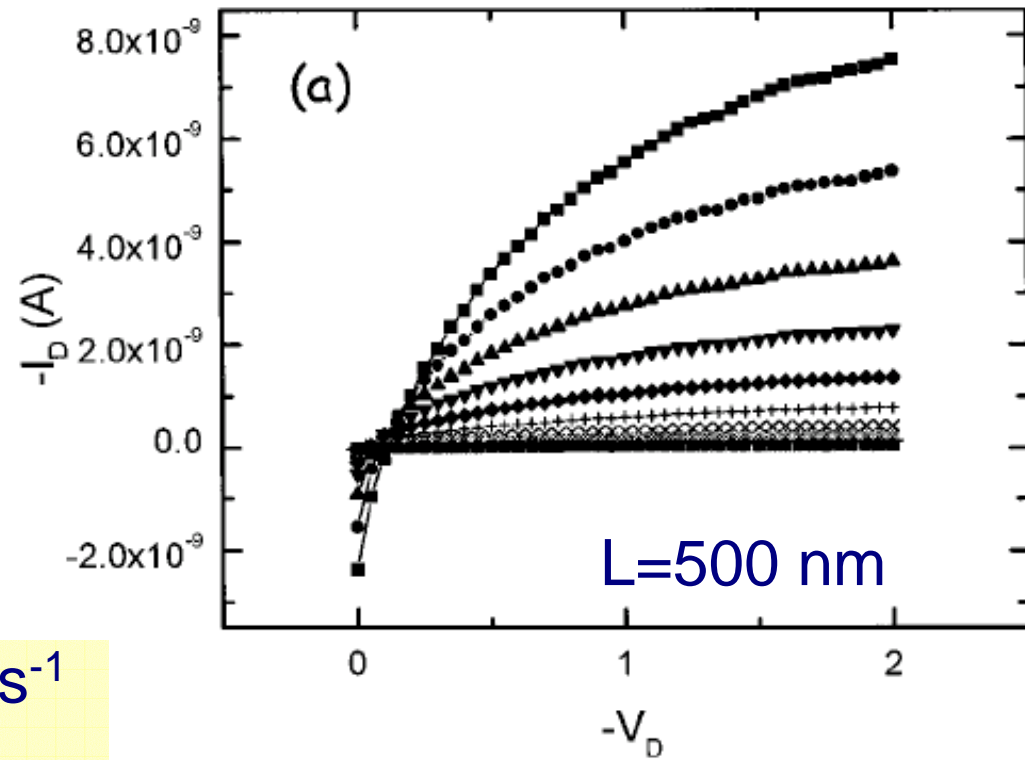
large area capacitors @ wafer level

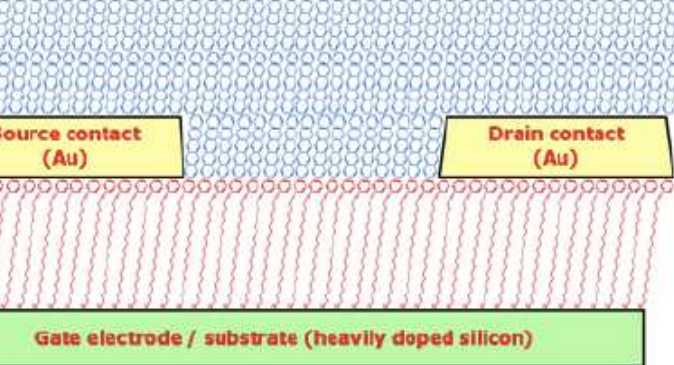


top S-D contacts



$\mu \approx 10^{-3} \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$
on/off $\approx 10^4$



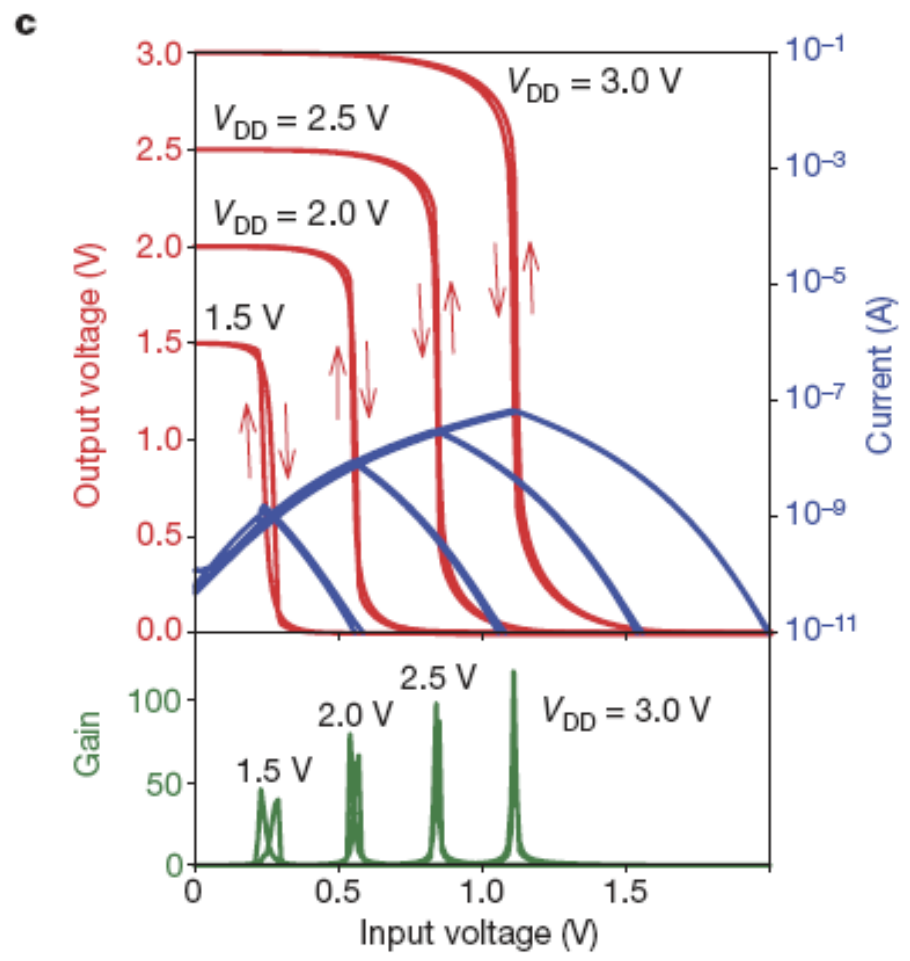
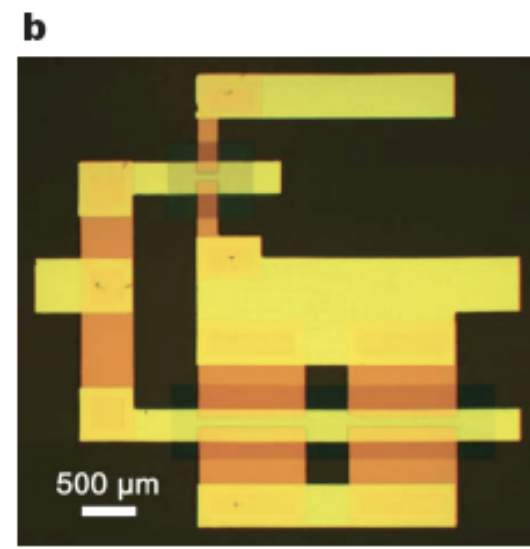
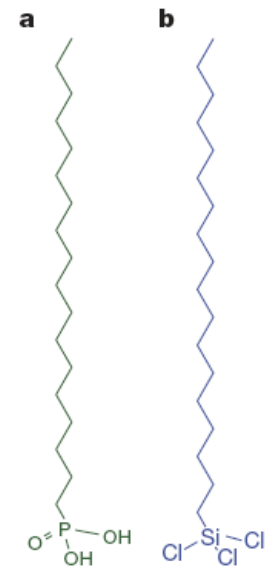
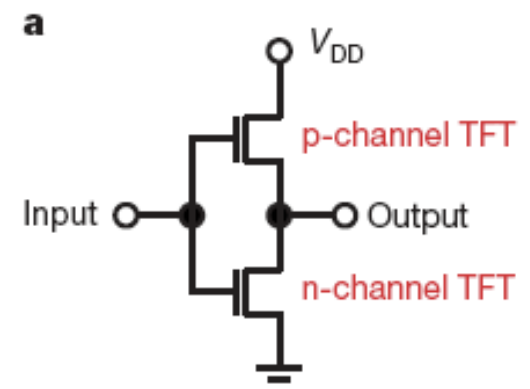


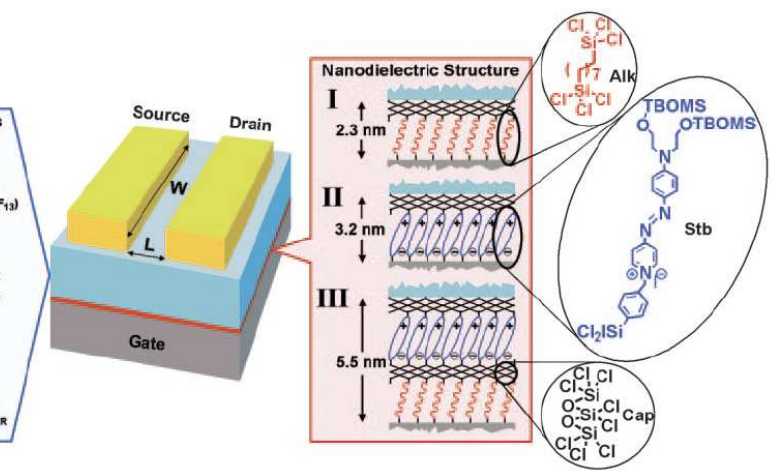
Pentacene organic active layer

Photolithographically patterned contacts

Self-assembled monolayer (SAM) gate dielectric (2.5 nm)

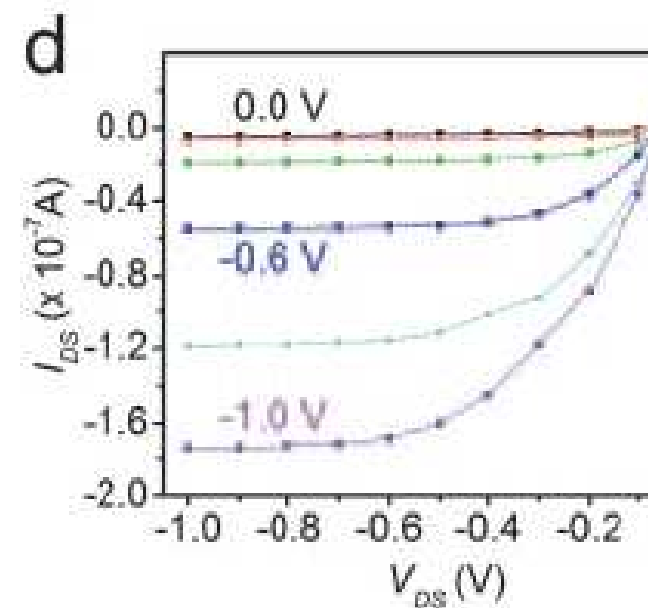
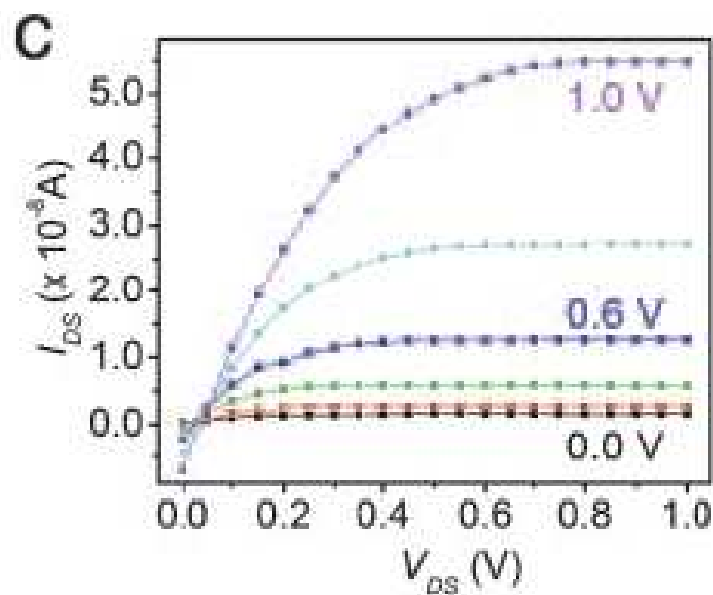
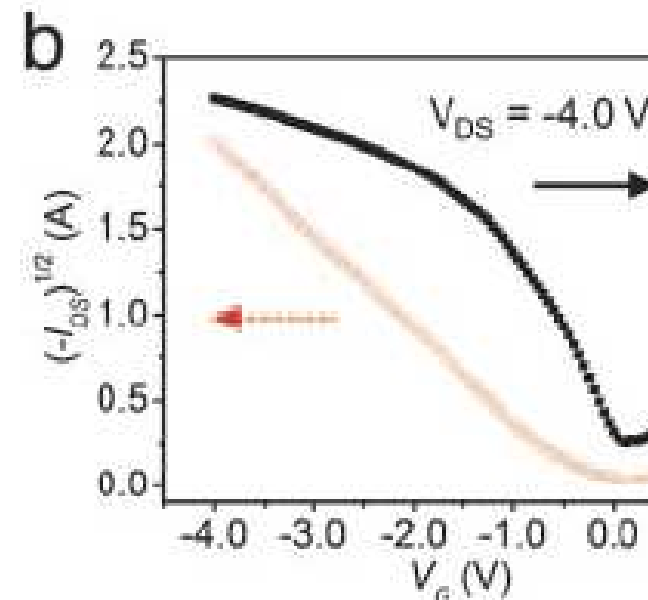
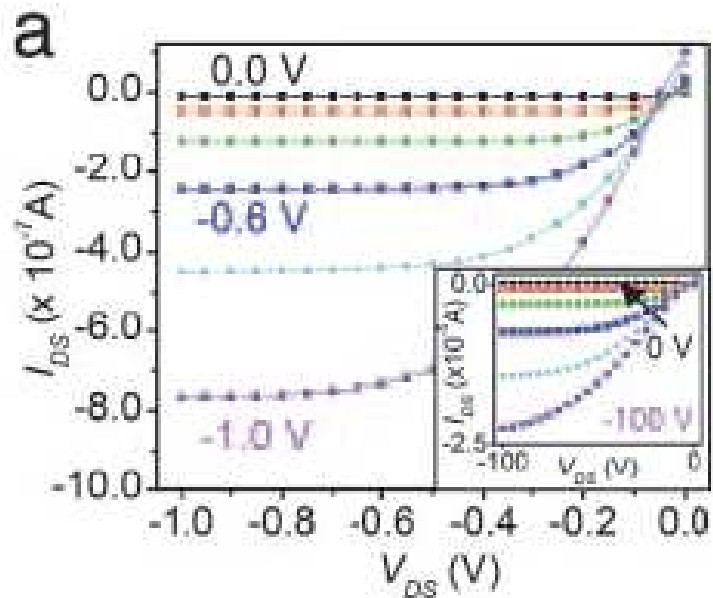
bottom S-D contacts

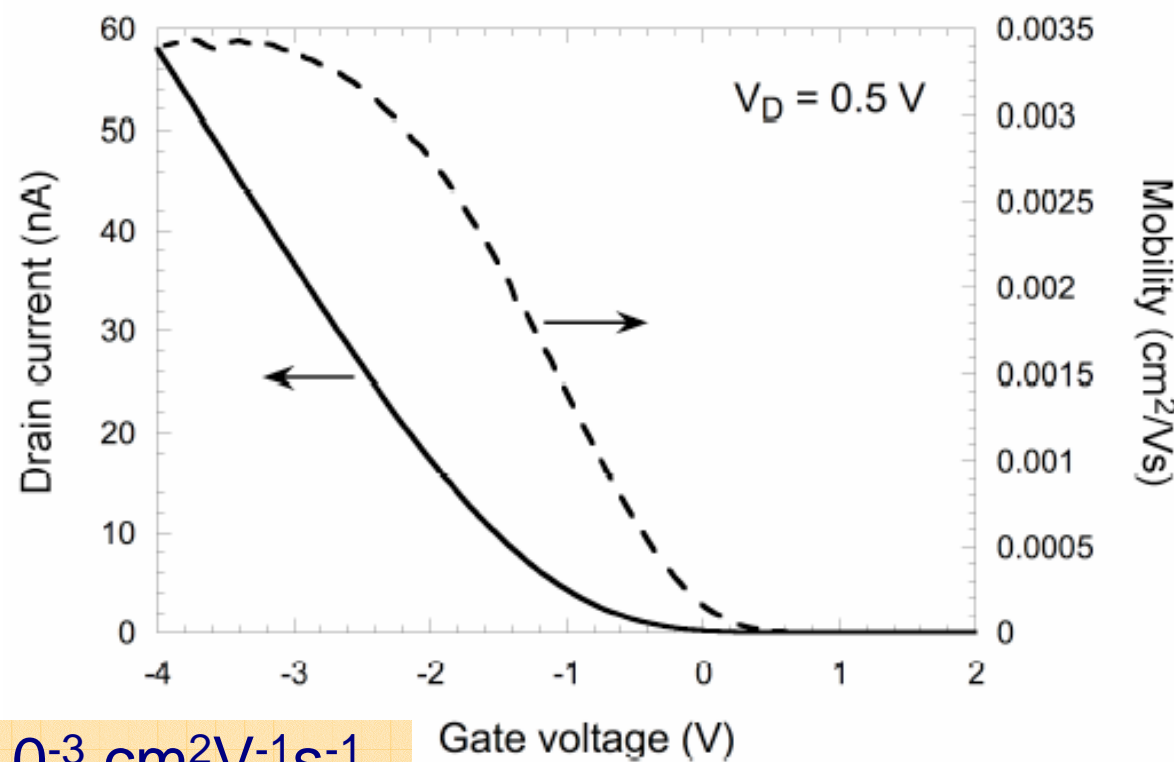
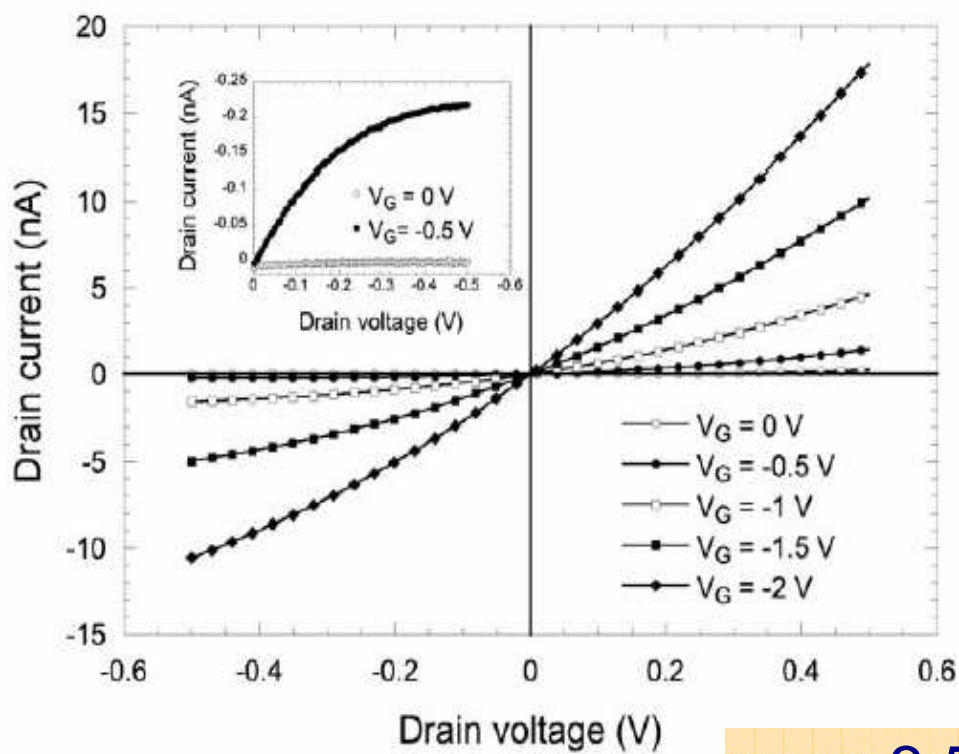
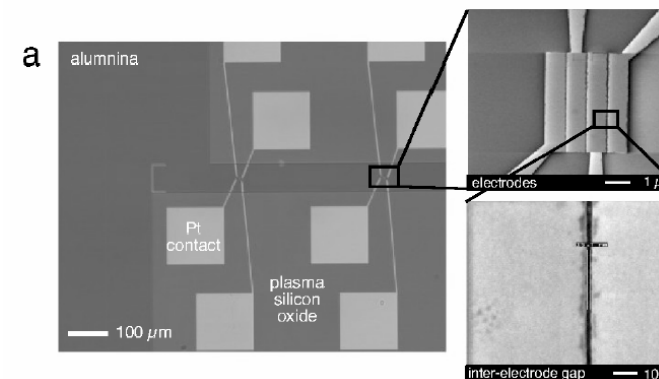
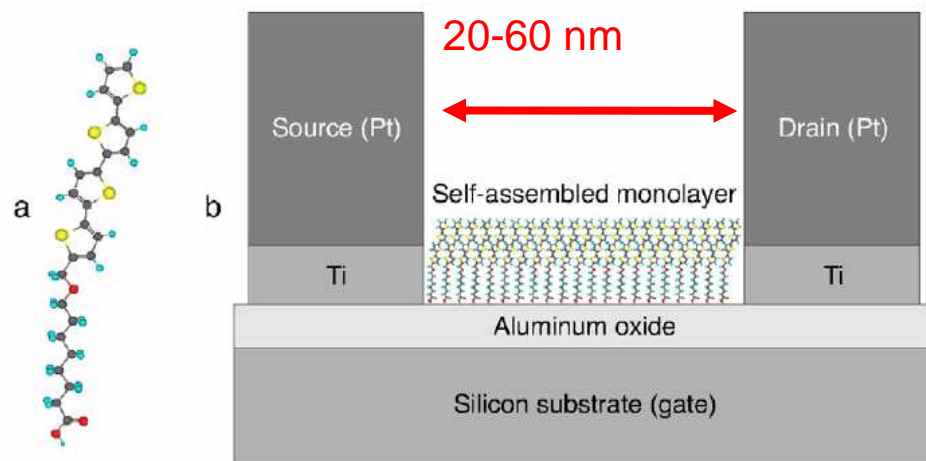




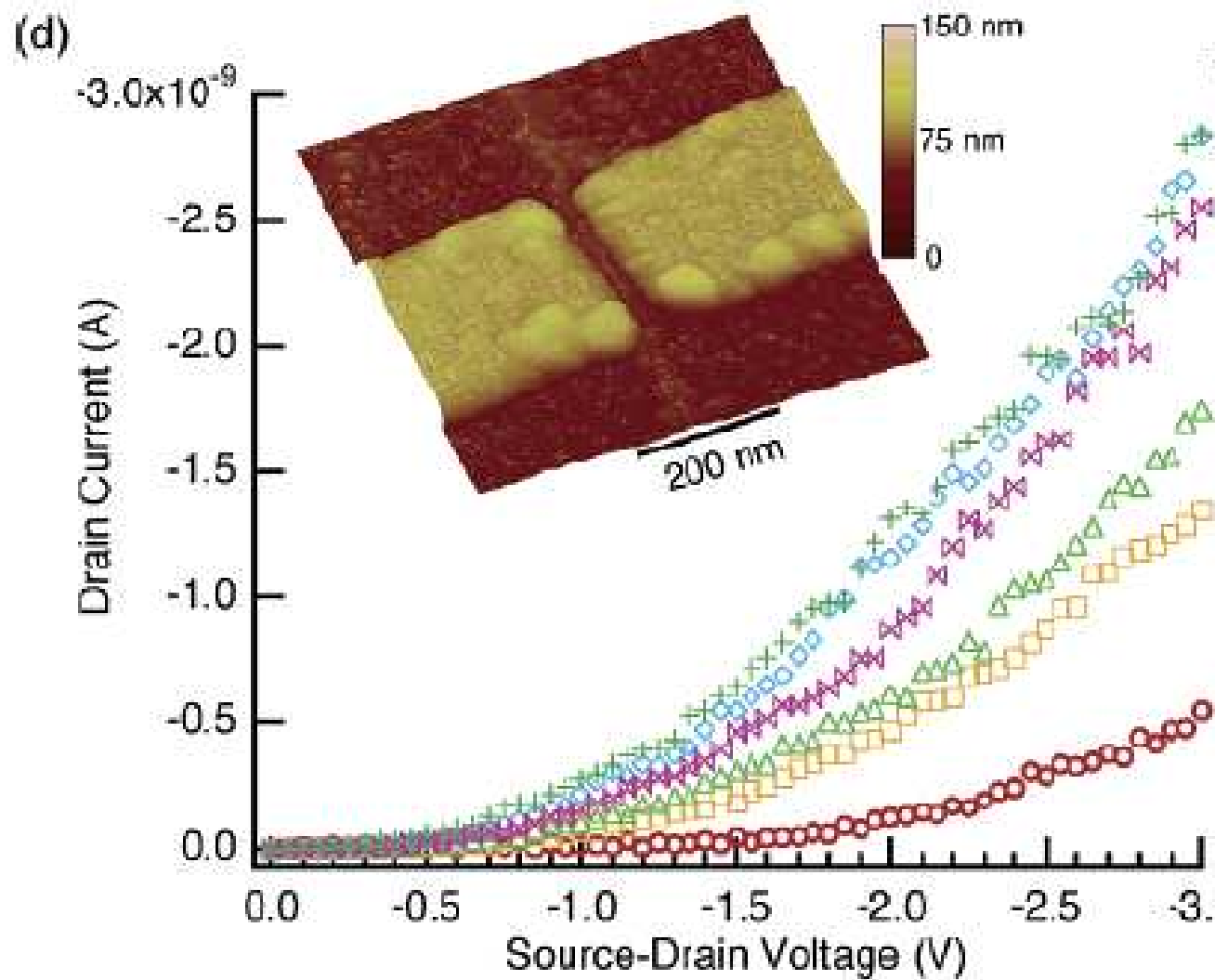
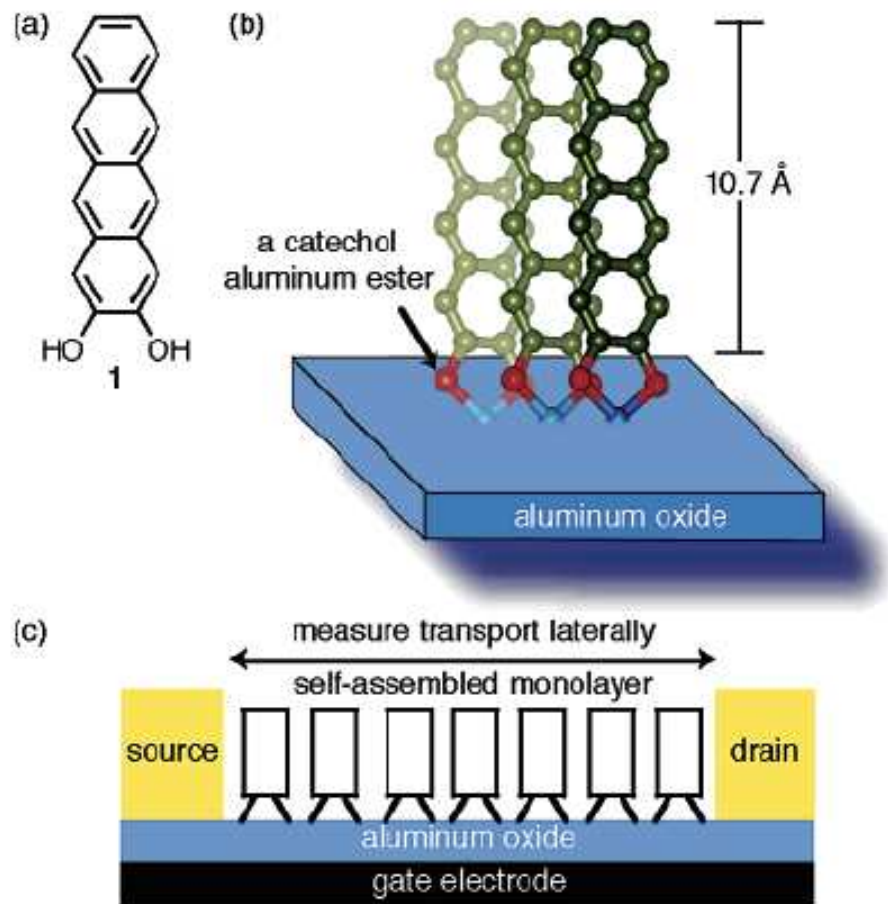
n- and p-type OSC
 μ: up to 10⁻² cm²V⁻¹s⁻¹
 on/off: up to 10⁵

with CNT 2D network FET





$$\mu_{\text{max}} = 3.5 \times 10^{-3} \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$$



in the two cases, $L \leq 200$ nm

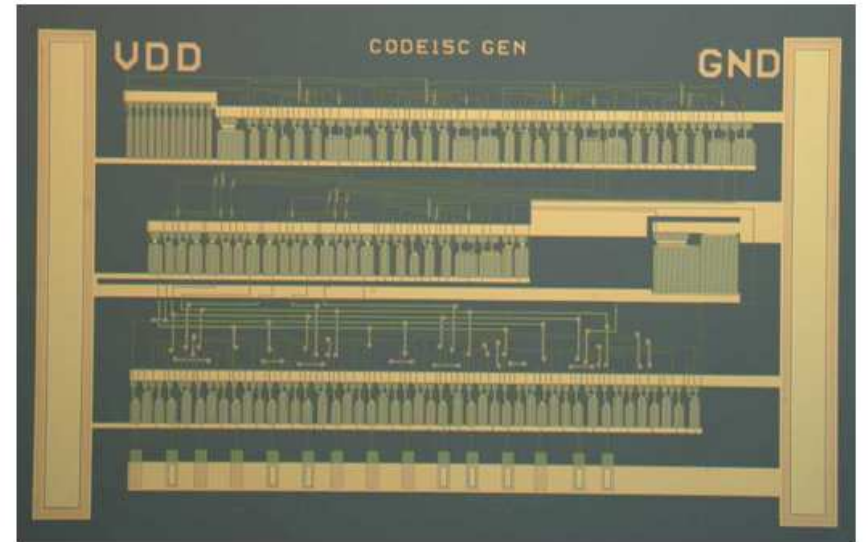
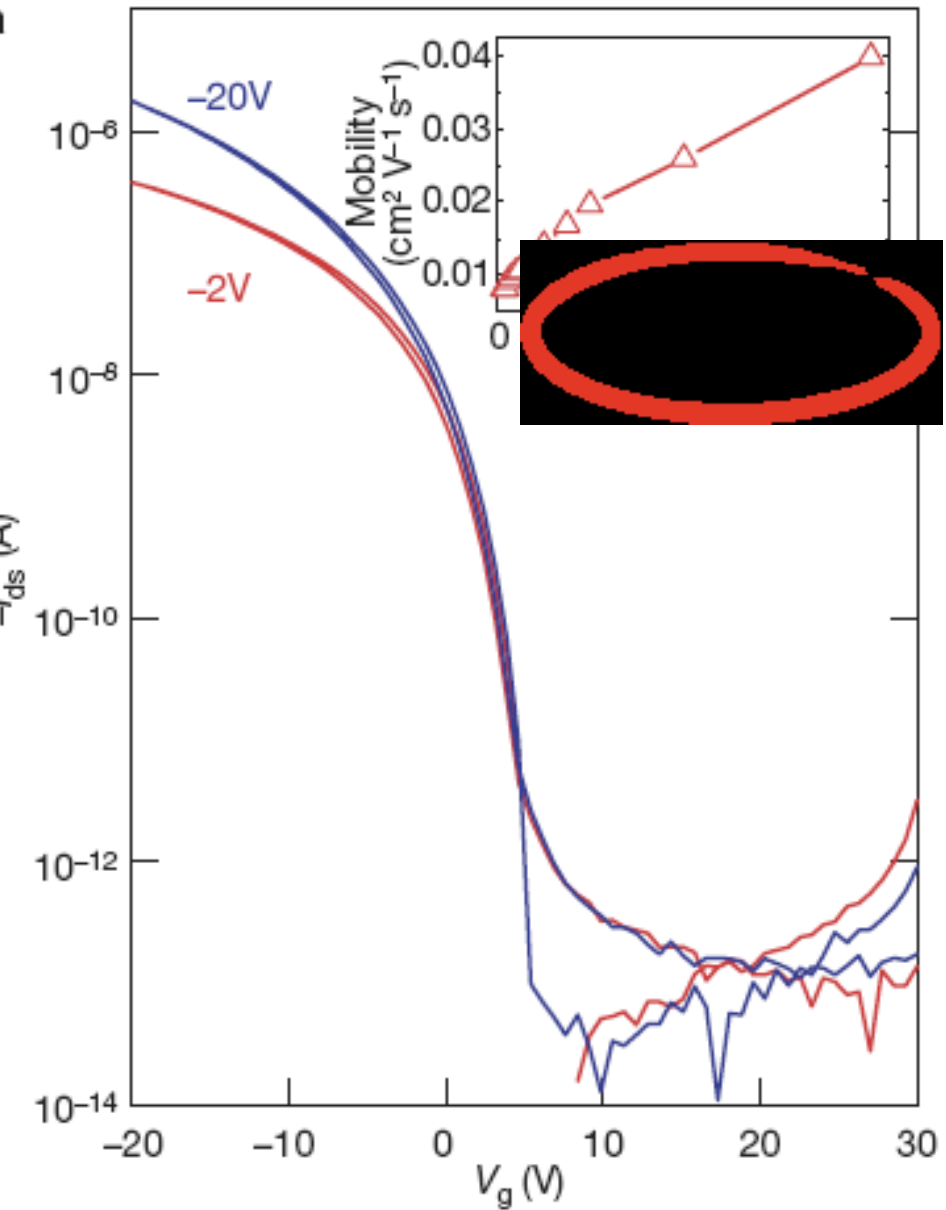
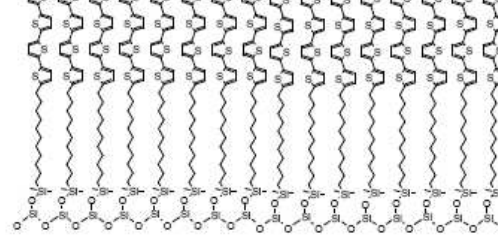
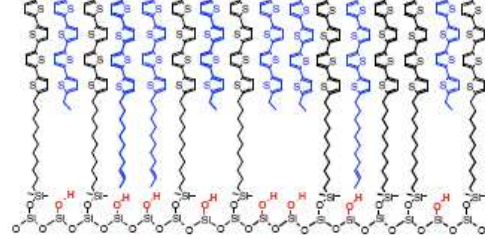
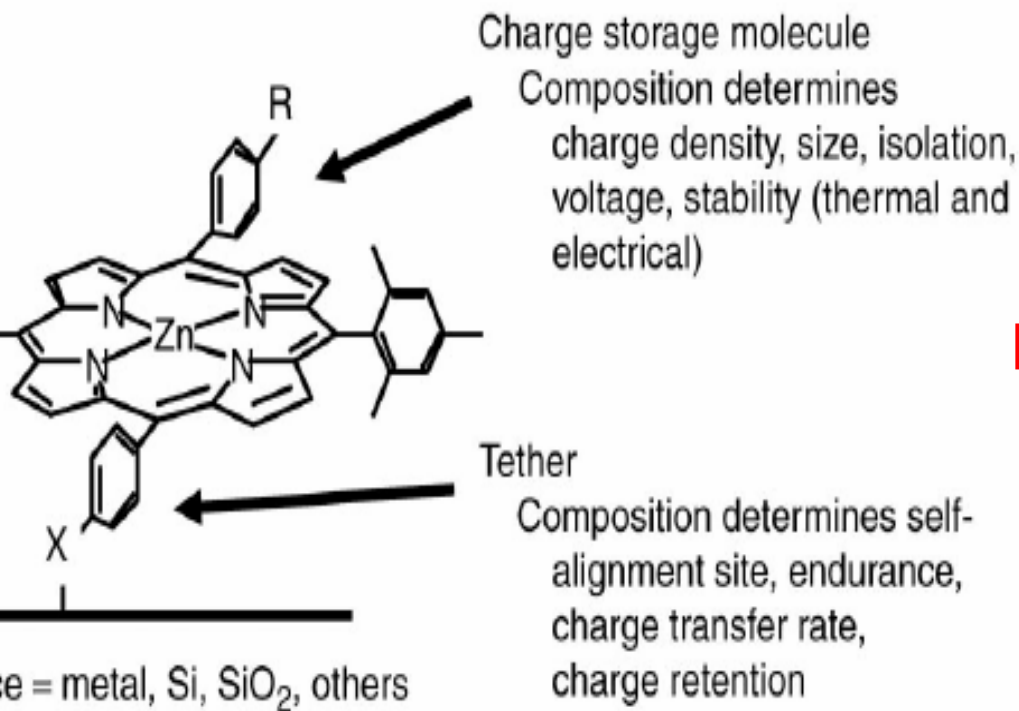


Fig. S31. Optical photograph of a functional 15-bit SAMFET code generator circuit combines over 300 SAMFETs.

15-bit code generator
300 SAMFETs

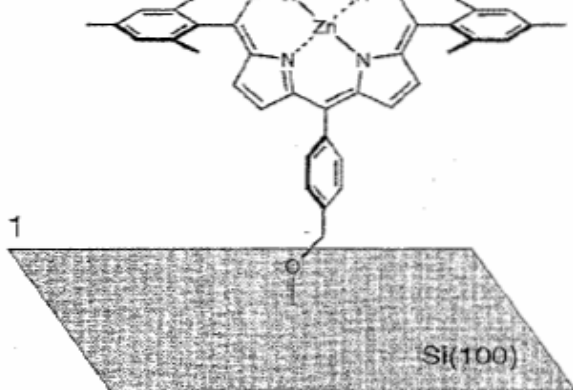


Principle 1 : charge storage on a redox molecule

porphyrins

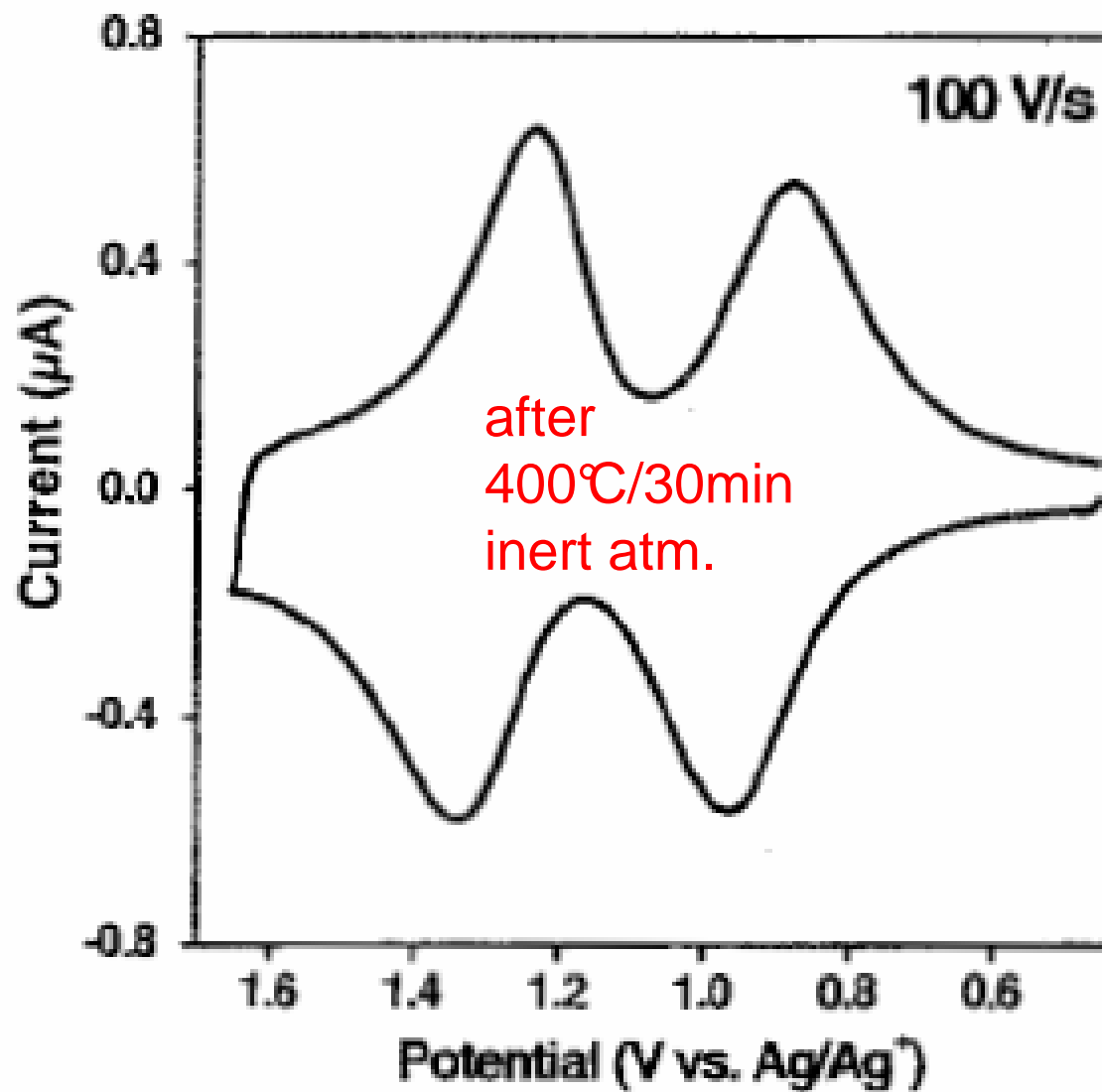
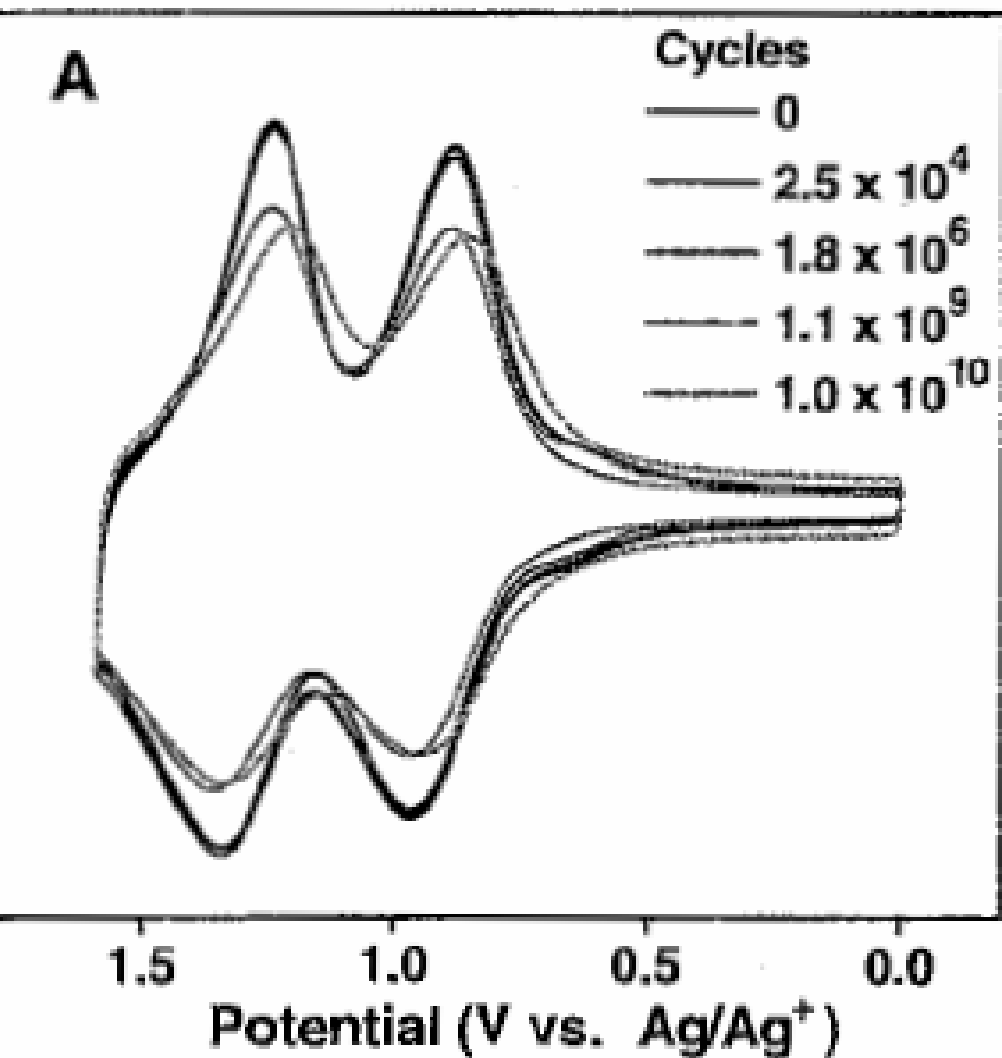
Table I: Criteria for Incorporation of Molecules in CMOS Storage Devices

Property	Implementation
Chemical stability	Delocalized cationic charge
Thermal stability	$T_{\text{decomposition}} > 400^{\circ}\text{C}$.
Endurance	$> 10^{15}$ cycles
Read/write speed	$t_{\text{R/W}} = 1/k_{\text{eff}} < 10$ ns
Charge retention half-life	$t_{1/2} > 10$ s
Charge density	
Self-assembly and self-alignment	selective covalent bond formation molecules to specific substrate



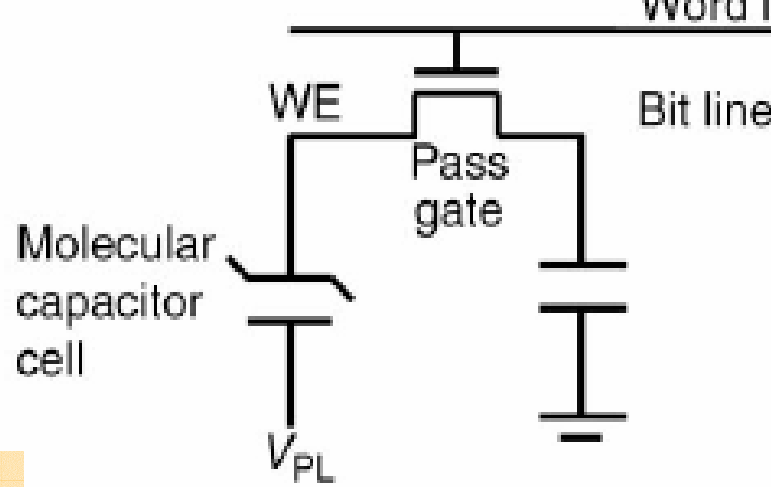
direct grafting on Si-H
CMOS compatible

survive a 400°C process



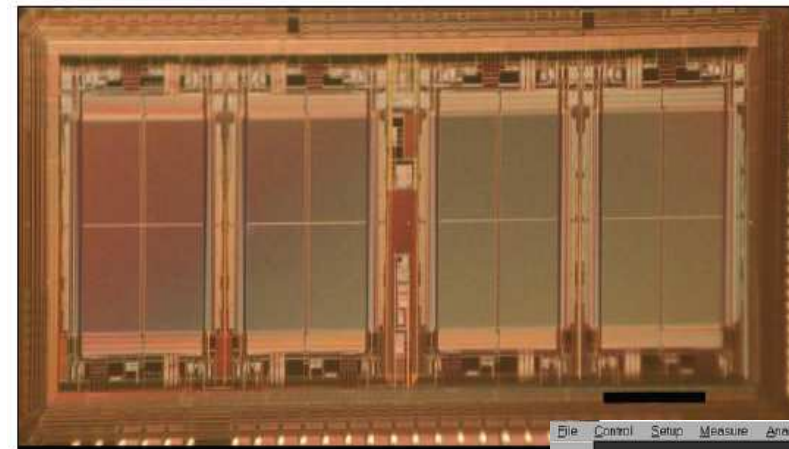
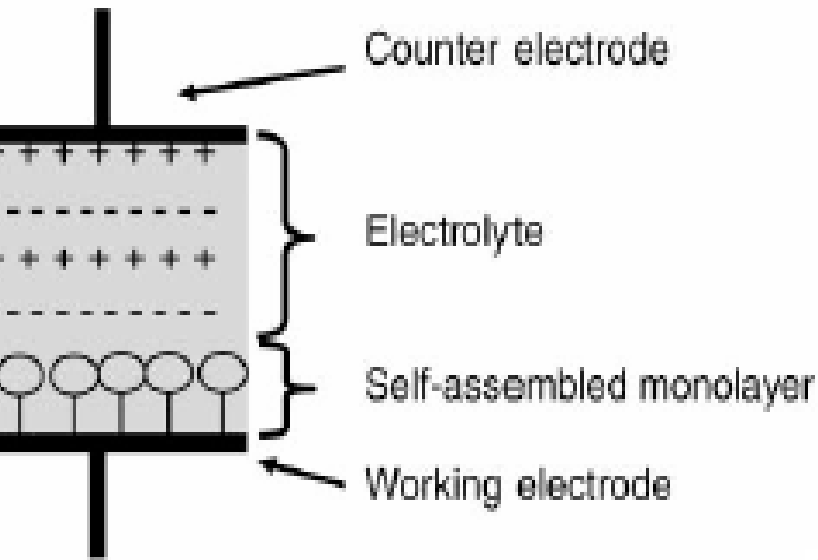
working stability: up to 10^{12} cycles

1Mbit / molDRAM Zettacore

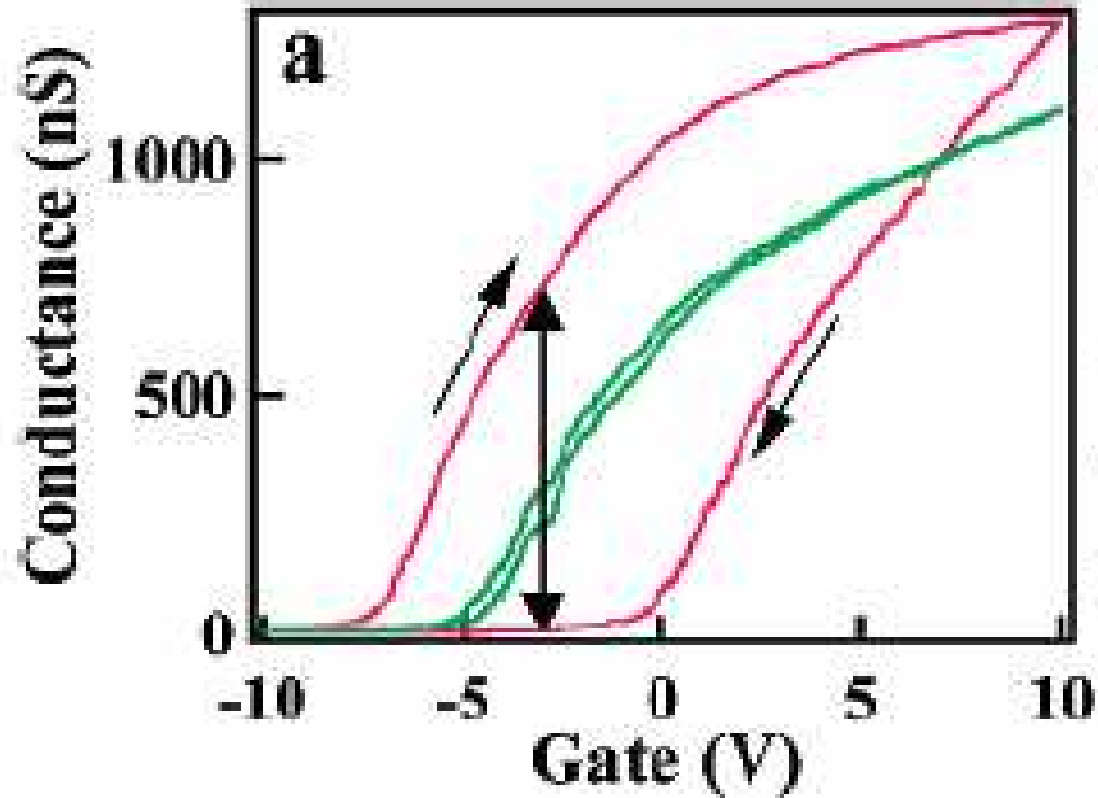
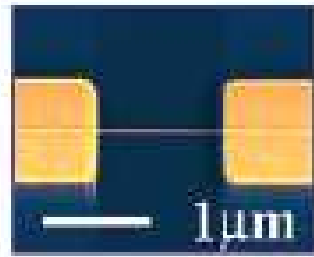
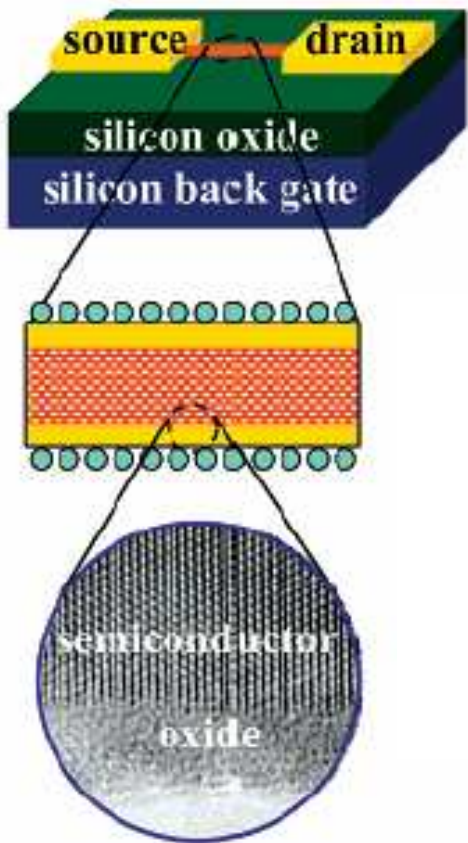


planar (no trench, no stack)
10% steps/Si DRAM

10 μ s (theory: 10 ns)
on : few hundred sec



- Evaluations performed to confirm circuit functionality
- Write, read, addressing capability

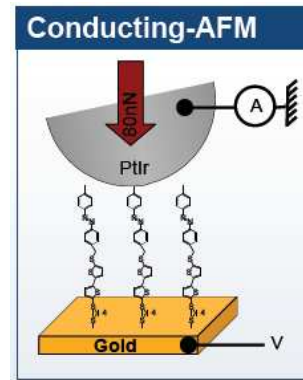
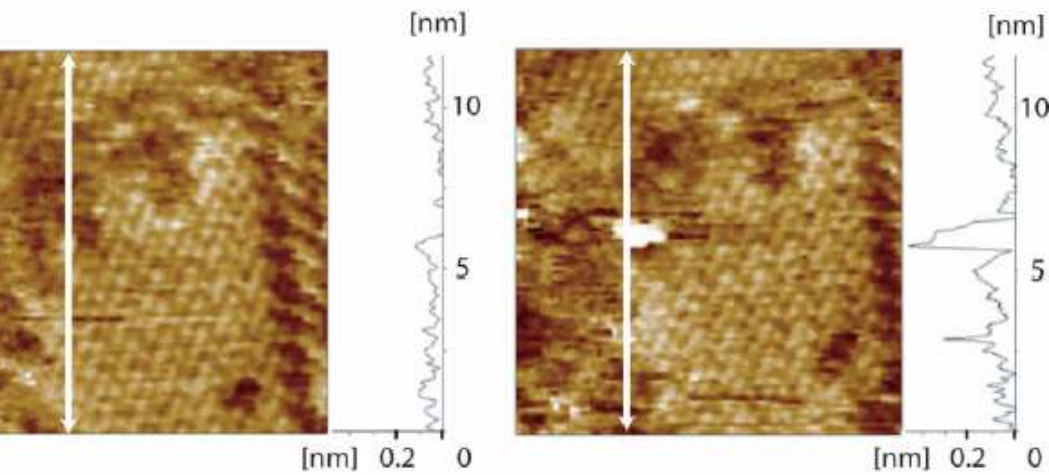
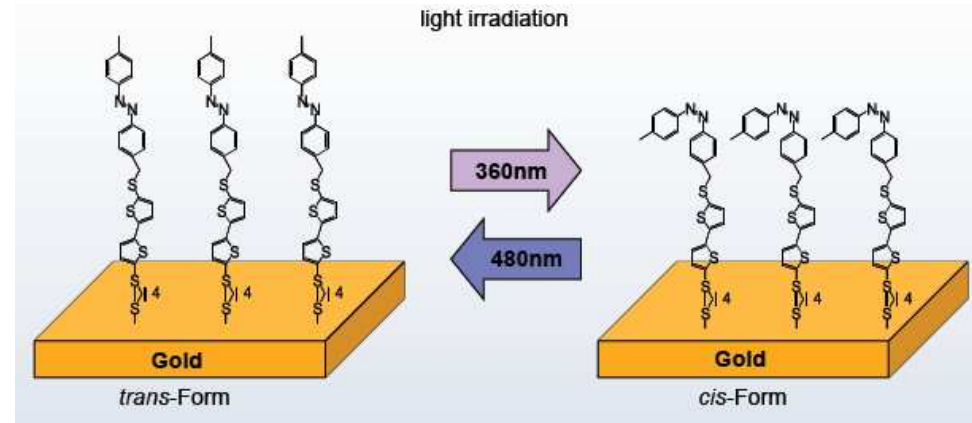
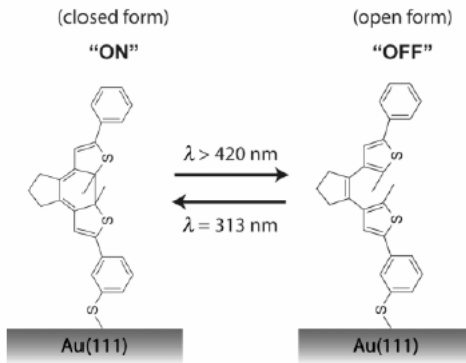


InP (10-30 nm)
 molecules = Co phthalocyanine

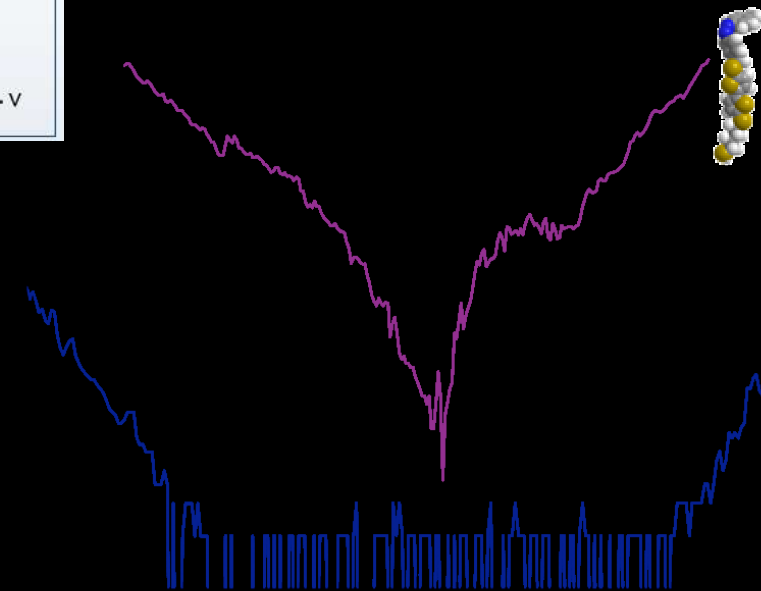
on/off $\approx 10^4$
 retention time $\approx 10^4$ s

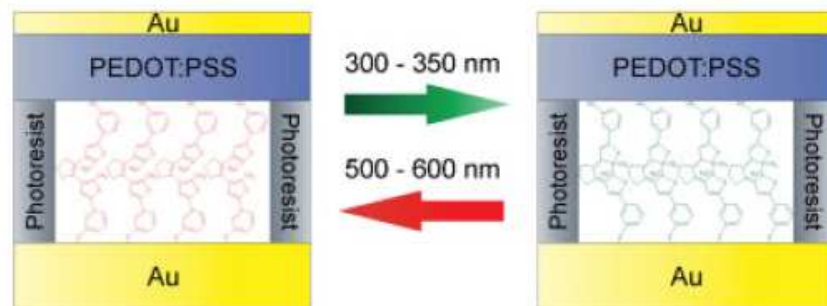
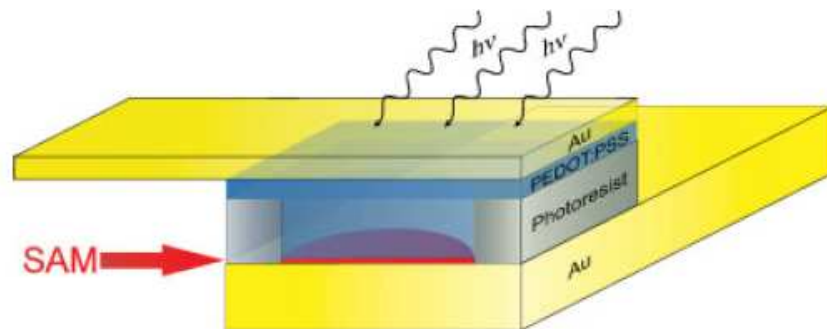
azobenzene derivative

diarylethene

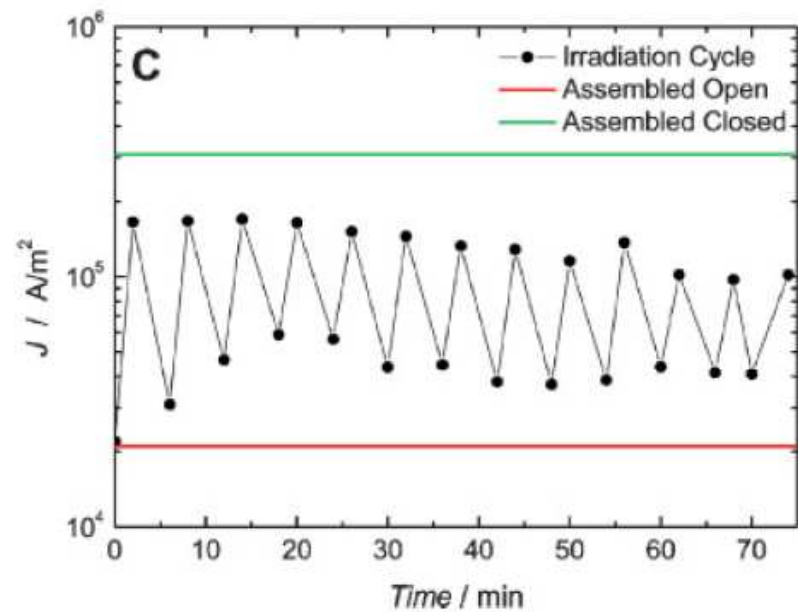
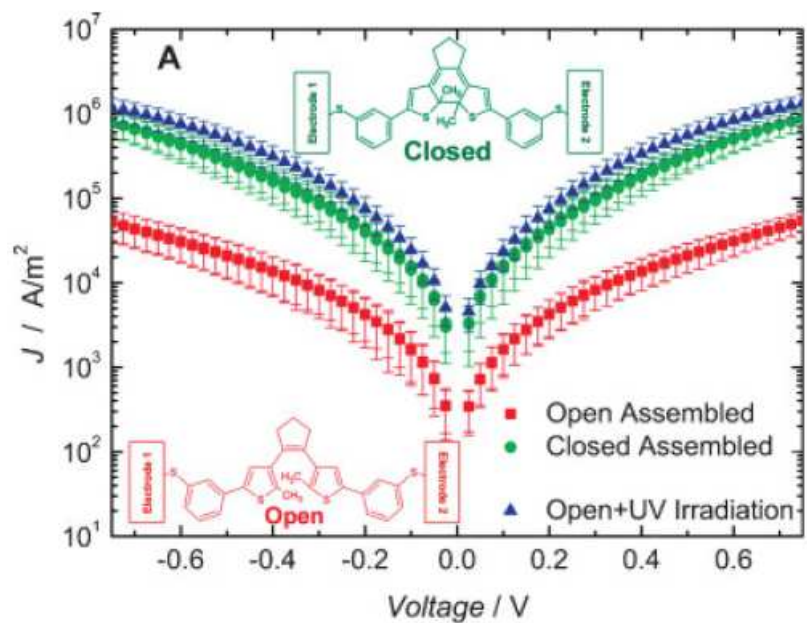


on/off $\approx 2 \times 10^3$





suitable for large-area electronics



Thank you for your attention